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ISSUE CLASSIFICATION	
Class	Subclass

PATE^{NT} NUMBER

U.S. UTILITY Patent Application

<p>O.I.P.E.</p> <p>SCANNED <u>HKM</u> Q.A. <u>AB</u></p>	<p>PATENT DATE</p>
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APPLICATION NO. 09/920499	CONT/PRIOR D	CLASS 156 <i>216</i>	SUBCLASS <i>83</i>	ART UNIT 1734 <i>1746</i>	EXAMINER <i>Alfred</i>
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APPLICANTS

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Masud Beraz

752

74.1

1765

Wamp - Frein,

TITLE

Wet etch process and conditions for forming openings in a polymer substrate

PTO-2040
12/89

ISSUING CLASSIFICATION

[illegible]

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner)		NOTICE OF ALLOWANCE MAILED	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____	_____ (Primary Examiner)		ISSUE FEE	
			Amount Due	Date Paid
<input type="checkbox"/> The terminal ____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner)		ISSUE BATCH NUMBER	

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